

Dear Candidate,

We are pleased to inform that you have been shortlisted for the Written Entrance Test & Interview for NIFT Lateral Entry Admission (NLEA).

The Written Entrance Test & Interview will be held on 28th June 2013 at all 15 NIFT Campuses. Hence, you are instructed to appear for the same at the NIFT Campus where you have submitted the application forms. The schedule for the examination is as below:

S. No.	Name of exam	Marks	Courses	Time	Venue
1	GAT	100	B.Des and BFTech	10.00 am to 11.00 am	NIFT Centre where you have submitted the application forms
2	Studio Test	100	B.Des	11.30 am to 01.00 pm	
3	TAT	100	BFTech	11.30 am to 01.00 pm	
4	Interview	100	B.Des and BFTech	01.30 pm onwards	

1. General Ability Test (GAT) for B. Des & B.F.Tech

This test will comprise of various section as given below:

- a. Quantitative Ability
- b. Communication Ability
- c. English Comprehension
- d. Analytical Ability
- e. General Knowledge and Current Affairs

2. Technology Ability Test (TAT)

The Technology Aptitude Test (TAT) may include the following three components:

- a. Textile Appreciation
- b. Geometry
- c. Corporate Social Responsibility, Intellectual Property Rights, Professional Practices (combined).

3. Studio Test

Shortlisted candidates for B. Des from the written entrance examination are required to undergo a Studio Test which is a hands-on test to evaluate the candidate's skills for material handling and innovative ability on a given situation with a given set of materials.

4. Interview:

A candidate is judged by a panel on the various parameters as listed below:

- a. Career orientation
- b. Aptness for the field
- c. Overall personal achievements in academics and co-curricular activities
- d. Communication
- e. General awareness and aptitude, creative and Lateral thinking are likely to be useful.